

**AMENDMENTS TO THE CLAIMS**

1. (Currently Amended) A method of manufacturing a liquid crystal display comprising the steps of:

forming a liquid crystal cell including the steps of:

providing an upper substrate and a lower substrate;

forming an alignment layer on at least one of the upper and lower substrates;

forming a sealant on at least one of the upper and lower substrates;

laminating the upper and lower substrates; and

injecting [[a]] **the** liquid crystal layer between the upper and lower substrates;

heating the liquid crystal cell, wherein the heating step is performed at a temperature ~~that is greater than~~ **of** about ~~10°C above a nematic-isotropic transition temperature~~ **100°C to about 170°C** to form a uniform tilt angle of the alignment layer; and

quickly cooling the liquid crystal cell.

**2-5.** (Canceled).

**6.** (Previously Amended) The method according to claim 1, wherein the alignment layer is made of polyimide.

**7.** (Previously Amended) The method according to claim 1, wherein the alignment layer is made of a photo-alignment material.

**8.** (Canceled).

**9.** (Previously Amended) The method according to claim 1, wherein the step of sealing further comprises the step of printing at least one of the substrates with a sealant.

**10.** (Original) The method according to claim 1, wherein the heating step is performed at a temperature that is less than a curing temperature of the sealant.

**11.** (Original) The method according to claim 7, wherein the photo-alignment material includes at least one of polysiloxane and cellulose cinnamate.

**12.** (Canceled).

**13.** (Original) The method according to claim 1, wherein the heating step is performed at a temperature which is substantially equal to a baking temperature of the alignment layer.

**14.** (Currently Amended) A method of manufacturing a liquid crystal display comprising the steps of:

forming a liquid crystal cell including the steps of:

providing an upper substrate and a lower substrate;

forming an alignment layer on at least one of the upper and lower substrates;

forming a sealant on at least one of the upper and lower substrates;

laminating the upper and lower substrates; and

injecting ~~[[a]]~~ **the** liquid crystal layer between the upper and lower substrates; and

heating the liquid crystal cell, wherein the heating step is performed at a temperature ~~that is greater than~~ **of** about 10°C ~~above a nematic-isotropic transition temperature~~ **100°C to about 170°C** to form a uniform tilt angle of the alignment layer.

**15.** (Original) The method according to claim 14, wherein the heating step is performed at a temperature that is less than a curing temperature of the sealant.

**16.** (Canceled).

**17.** (Original) The method according to claim 14, wherein the heating step is performed at a temperature which is substantially equal to a baking temperature of the alignment layer.